

**Joachim Dahl Thomsen<sup>1</sup>**Jens Kling<sup>2</sup>, David MA Mackenzie<sup>1</sup>, Peter Bøggild<sup>1</sup>, Timothy J. Booth<sup>1</sup><sup>1</sup>Center for Nanostructured Graphene, Department of Micro- Nanotechnology, Technical University of Denmark, Lyngby, Denmark<sup>2</sup>Center for Electron Nanoscopy, Technical University of Denmark, Lyngby, Denmark

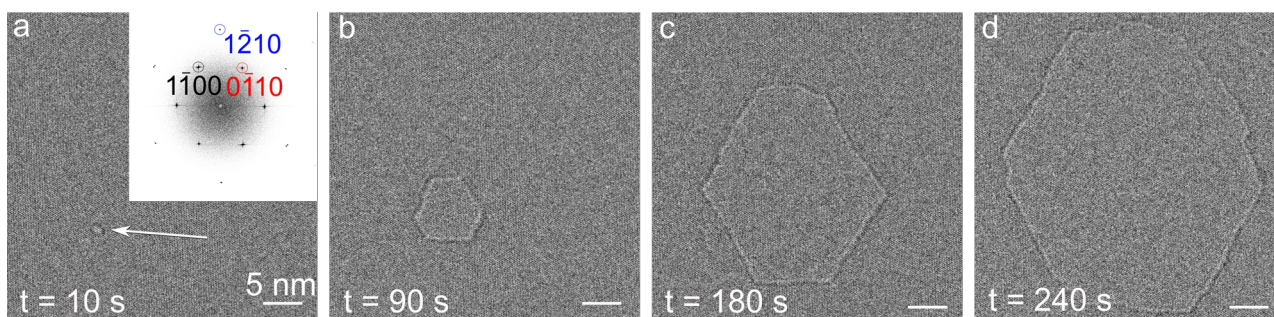
jdth@nanotech.dtu.dk

**Anisotropic Oxidation and Unexpected Stability in Suspended Graphene**

We study the oxidation of clean suspended mono- and few-layer graphene in real-time by in situ environmental transmission electron microscopy. At pressures below 0.1 mbar we observe anisotropic oxidation and the formation of hexagonal holes with armchair-oriented edges and edge roughness below 1 nm. At higher pressures we observe increasingly isotropic oxidation, and eventually irregular holes at a pressure of 6 mbar. In addition, we find that few-layer flakes are stable against oxidation at temperatures up to at least 1000 °C in the absence of impurities and electron beam-induced defects. These findings show first that the oxidation behavior of mono- and few-layer graphene depends critically on the roughness, cleanliness and supporting substrate. Second, the activation energy for oxidation of pristine suspended few-layer graphene is up to 43 % higher than previously reported for graphite. In order to study the oxidative etching of suspended graphene, we have developed a cleaning scheme that results in the near complete removal of hydrocarbon residues over the entire visible sample area (~50  $\mu\text{m}^2$ ) [1, 2]. These results have implications for applications of graphene where edge roughness can critically affect the performance of devices, and more generally highlights the surprising (meta)stability of the basal plane of suspended bilayer and thicker graphene towards oxidative environments at high temperature.

**References**

- [1] J. D. Thomsen, J. Kling, D. M. A. Mackenzie, P. Bøggild, T. J. Booth, submitted (2018)
- [2] J. D. Thomsen, T. Gunst, S. S. Gregersen, L. Gammelgaard, B. S. Jessen, D. M. A. Mackenzie, K. Watanabe, T. Taniguchi, P. Bøggild, T. J. Booth, *Physical Review B*, 96 (2017) 014101

**Figures****Figure 1:** TEM images of suspended graphene etched in 0.1 mbar oxygen at a temperature of 800 °C